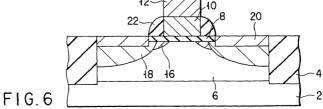
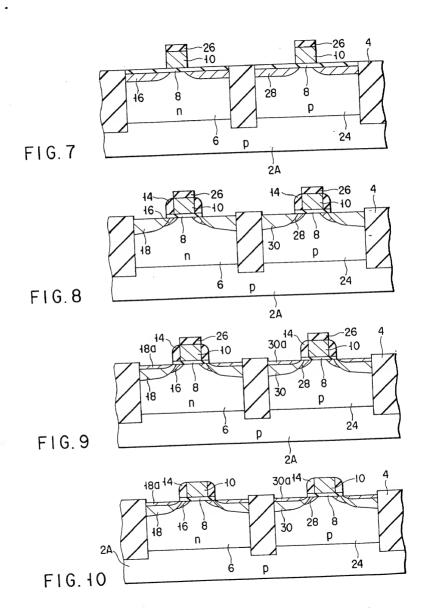
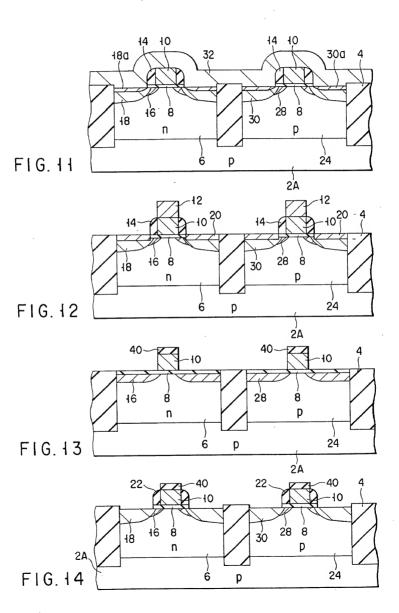


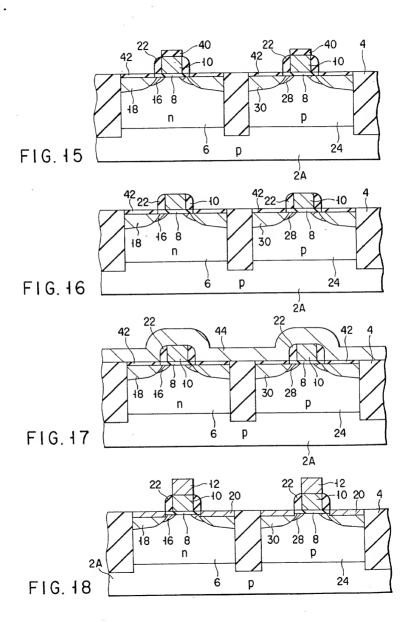
FIG. 5

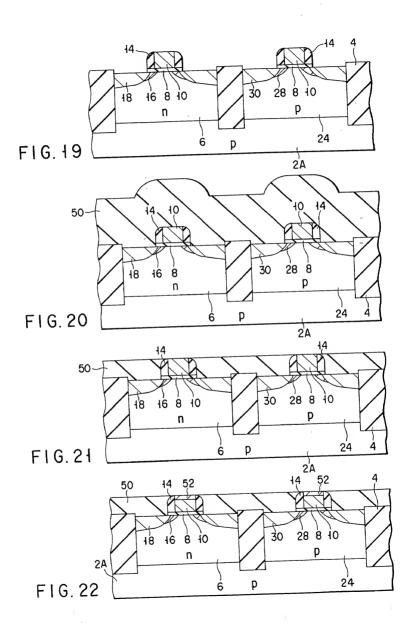
RATIO OF SILICIDE FILM THICKNESS ON GATE ELECTRODE TO SILICIDE FILM THICKNESS ON SOURCE-DRAIN ELECTRODE (Tg/Tsd)

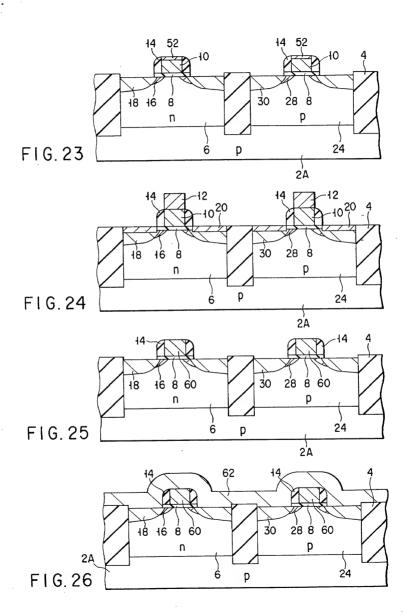


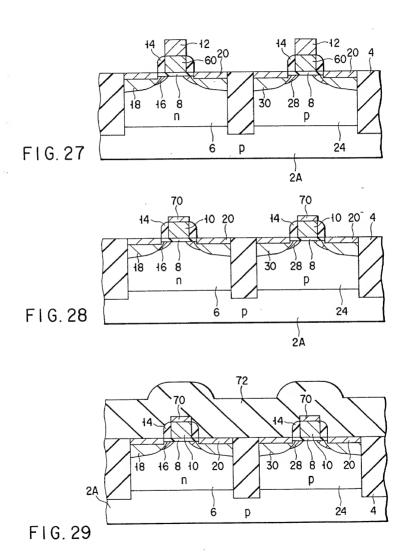


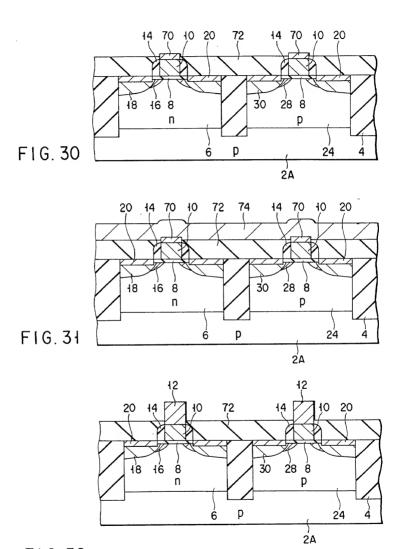












F1G. 32